

## Enhancing the durability of Pt nanoparticles for water electrolysis using ultrathin SiO<sub>2</sub> layers

Li, M.; Saedy, S.; Fu, S.; Stellema, T.P.; Kortlever, R.; van Ommen, J.R.

**DOI**

[10.1039/D3CY00996C](https://doi.org/10.1039/D3CY00996C)

**Publication date**

2024

**Document Version**

Final published version

**Published in**

Catalysis Science & Technology

**Citation (APA)**

Li, M., Saedy, S., Fu, S., Stellema, T. P., Kortlever, R., & van Ommen, J. R. (2024). Enhancing the durability of Pt nanoparticles for water electrolysis using ultrathin SiO<sub>2</sub> layers. *Catalysis Science & Technology*, 14(5), 1328-1335. <https://doi.org/10.1039/D3CY00996C>

**Important note**

To cite this publication, please use the final published version (if applicable). Please check the document version above.

**Copyright**

Other than for strictly personal use, it is not permitted to download, forward or distribute the text or part of it, without the consent of the author(s) and/or copyright holder(s), unless the work is under an open content license such as Creative Commons.

**Takedown policy**

Please contact us and provide details if you believe this document breaches copyrights. We will remove access to the work immediately and investigate your claim.

Cite this: *Catal. Sci. Technol.*, 2024,  
14, 1328

## Enhancing the durability of Pt nanoparticles for water electrolysis using ultrathin SiO<sub>2</sub> layers†

Ming Li,<sup>ab</sup> Saeed Saedy,<sup>id</sup><sup>a</sup> Shilong Fu,<sup>b</sup> Teise Stellema,<sup>a</sup>  
Ruud Kortlever<sup>id</sup><sup>\*b</sup> and J. Ruud van Ommen<sup>id</sup><sup>a</sup>

Extending the lifetime of electrocatalytic materials is a major challenge in electrocatalysis. Here, we employ atomic layer deposition (ALD) to coat the surface of carbon black supported platinum nanoparticles (Pt/CB) with an ultra-thin layer of silicon dioxide (SiO<sub>2</sub>) to prevent deactivation of the catalyst during H<sub>2</sub> evolution. Our results show that after an accelerated durability test (ADT) the current density at -0.2 V vs. reversible hydrogen electrode (RHE) of the unprotected Pt/CB catalyst was reduced by 34%. By contrast, after coating the Pt/CB catalyst with 2 SiO<sub>2</sub> ALD cycles, the current density at the same potential was reduced by 7% after the ADT procedure, whereas when the Pt/CB sample was coated with 5 SiO<sub>2</sub> ALD cycles, the current density was reduced by only 2% after the ADT. Characterization of the Pt particles after electrochemical testing shows that the average particle size of the uncoated Pt/CB catalyst increases by roughly 16% after the ADT, whereas it only increases by 3% for the Pt/CB catalyst coated with 5 cycles of SiO<sub>2</sub> ALD. In addition, the coating also strongly reduces the detachment of Pt nanoparticles, as shown by a strong decrease in the Pt concentration in the electrolyte after the ADT. However, 20 cycles of SiO<sub>2</sub> ALD coating results in an over-thick coating that has an inhibitory effect on the catalytic activity. In summary, we demonstrate that only a few cycles of SiO<sub>2</sub> ALD can strongly improve the stability of Pt catalyst for the hydrogen evolution reaction.

Received 18th July 2023,  
Accepted 24th January 2024

DOI: 10.1039/d3cy00996c

rsc.li/catalysis

### Introduction

Hydrogen is a pivotal feedstock for the chemical industry and is one of the pillars of the energy transition, as it is a clean and sustainable energy carrier.<sup>1</sup> Currently, the most widely used method for hydrogen production is natural gas reforming, which emits large amounts of CO<sub>2</sub>, relies on fossil inputs, and produces blue or grey hydrogen. When integrated with renewable electricity production, water electrolysis yields nearly no CO<sub>2</sub> emissions during operation and produces green hydrogen.<sup>2</sup> Platinum (Pt) is one of the most effective electrocatalysts for both water reduction to hydrogen in polymer electrolyte membrane (PEM) electrolyzers and hydrogen oxidation in PEM fuel cells. However, as a noble metal, its high costs and scarcity limit its application.

To overcome these challenges, most of the research focusses on two potential solutions. The first approach is to

decrease the Pt amount in the electrolyzer and improve the Pt utilization efficiency *via* decreasing the Pt particle size. For instance, Wan *et al.*<sup>3</sup> confined sub-nanometer Pt clusters in hollow mesoporous carbon spheres to stabilize and immobilize the Pt clusters, enhancing the mass activity of the Pt catalyst. Additionally, Cheng *et al.*<sup>4</sup> produced isolated single Pt atoms and clusters on a N-doped graphene substrate using atomic layer deposition (ALD) and found that these have a higher activity compared to commercial Pt/C catalysts. This is due to their small sizes and the unique electronic interaction between the adsorbed Pt single atoms and N-doped graphene. The second approach is to protect the Pt catalyst from degradation and prolong its lifetime. The Pt catalysts used for water electrolysis mainly degrade *via* dissolution, catalyst detachment, and agglomeration processes as deactivation mechanisms.<sup>1,5</sup> Marichy *et al.*<sup>6</sup> combined electrospinning, microwave-assisted synthesis, and ALD to synthesize Pt nanoparticles on carbon fibers with a SnO<sub>2</sub> coating. They found that with the SnO<sub>2</sub> coating, the Pt catalyst durability increased remarkably during voltage cycling between 0.6 V and 1.2 V vs. reversible hydrogen electrode (RHE) and that the activity towards the oxygen reduction reaction (ORR) increased slightly. The SnO<sub>2</sub> layer lowered the corrosion of the carbon support and prevented the aggregation of Pt particles. Kim *et al.*<sup>7</sup> found that a TiO<sub>2</sub>

<sup>a</sup> Department of Chemical Engineering, Faculty of Applied Sciences, Delft University of Technology, Van der Maasweg 9, 2629 HZ, Delft, The Netherlands

<sup>b</sup> Process & Energy Department, Faculty of Mechanical, Maritime and Materials Engineering, Delft University of Technology, Leeghwaterstraat 39, 2628 CB, Delft, The Netherlands. E-mail: R.Kortlever@tudelft.nl

† Electronic supplementary information (ESI) available. See DOI: <https://doi.org/10.1039/d3cy00996c>



coating can be used to enhance the activity and stability of Co/C catalysts for electrochemical water oxidation. The TiO<sub>2</sub> coating can prevent the catalyst from sintering as it decorates the undercoordinated Co nanoparticles at defects, corners, and edges, protecting those sites. However, the intrinsic instability of these metal oxides coatings remains a concern when they are applied for protection under reductive potentials.<sup>8</sup>

SiO<sub>2</sub> is stable under acidic (pH ≥ 2) as well as moderately alkaline (pH ≤ 10) conditions, and exhibits outstanding electrochemical stability under both reductive and oxidative potentials.<sup>9,10</sup> Its high-temperature resistance is also outstanding, allowing it to remain stable up to 650 °C.<sup>11,12</sup> This makes it a suitable material for catalyst protection and therefore it is already used for the protection of catalysts in thermochemical and photochemical processes. For example, Wang *et al.*<sup>13</sup> used SiO<sub>2</sub> to introduce a strong metal-support interaction with Cu catalysts and to stabilize these catalysts for hydrogenation reactions. Li *et al.*<sup>14</sup> applied SiO<sub>2</sub> to encapsulate cobalt oxide nanoparticles used as methane combustion catalyst. They found that the embedded CoO<sub>x</sub>@SiO<sub>2</sub> catalyst showed superior performance compared to the bare supported CoO<sub>x</sub>@SiO<sub>2</sub> catalyst. Trompoukis *et al.*<sup>15</sup> used SiO<sub>2</sub> to protect a Pt photocatalyst and found that the SiO<sub>2</sub> can increase the minority carrier lifetimes and avoids the growth of thin interfacial oxide between the photoactive material and the catalyst. Takenaka *et al.*<sup>16</sup> used an impregnation method to deposit different amounts of SiO<sub>2</sub> on a Pt/CB electrocatalyst to increase the durability of this catalyst in a polymer electrolyte fuel cell (PEFC). However, due to the impregnation method they used, the lowest SiO<sub>2</sub> coating loading achieved in the catalyst is 12.5 wt%, which, while considered low, still represents a relatively high percentage. While the durability of the catalyst used at the cathode is increased, the relatively thick SiO<sub>2</sub> coating decreases the Pt/CB catalyst activity. Since SiO<sub>2</sub> is more insulating than the metal oxides mentioned before, minimizing the coating thickness is crucial to maintain the electrical conductivity of the catalyst during electrocatalysis to avoid inactivate the catalyst. As such, very thin insulator films (thickness of <2 nm) are still conductive due to the tunneling effect, while very thick coatings will have a suppressive effect on the catalytic activity.<sup>17,18</sup> To achieve a uniformly covered surface of the catalyst with an ultrathin coating, a gentle and delicate method with precise control at the nanometer scale is required. ALD is a suitable choice due to its sub-nanometer control over layer thickness, enabling the production of uniform and conformal coatings on various surfaces.<sup>19</sup> Furthermore, investigating the impact of the SiO<sub>2</sub> coating on the water splitting, rather than application in a PEFC, is also necessary.

In this work, we demonstrate the potential of ultrathin SiO<sub>2</sub> coatings made *via* ALD to enhance the stability of commercial Pt on carbon black (Pt/CB) catalysts for the hydrogen evolution reaction. We find that an ultrathin SiO<sub>2</sub> coating can efficiently provide a strongly protective effect,

preventing the catalyst from agglomeration and detachment in accelerated durability tests (ADT). While the thickness of the protective layer has a stronger effect on catalyst performance than was previously recognized.

## Experimental section

### Materials

Silicon tetrachloride (SiCl<sub>4</sub>, 99%) was purchased from Alfa Aesar, isopropanol (≥98%) was purchased from Honeywell, Nafion™ perfluorinated resin solution (5 wt% in lower aliphatic alcohols and 15–20% water) and sulfuric acid (H<sub>2</sub>SO<sub>4</sub>, 95–97%) were purchased from Sigma-Aldrich. Deionized water with the resistivity of 18.2 MΩ were used as the co-reactant. 40 wt% of Pt on carbon black – Vulcan XC 72R catalyst was purchased from the FuelCell store. Glassy carbon rods and glassy carbon plates were ordered from HTW Hochttemperatur-Werkstoffe GmbH (Germany). The electrolyte solution was prepared from ultrapure water (Milli-Q IQ 7000, 18.2 MΩ). All chemicals were received and used without further purification.

### Catalyst synthesis

The SiO<sub>2</sub> coatings on the catalyst were deposited in a custom-built flat substrate ALD reactor<sup>19–21</sup> operating at atmospheric pressure. The reactor chamber consists of a metal cylinder with an inner diameter of 40 mm and a length of 190 mm, along with a substrate holder with dimensions of 30 mm by 125 mm. The deposition temperature was monitored and controlled using two thermocouples installed inside and outside wall of the ALD reactor to ensure an even temperature profile. We employed atmospheric pressure ALD here instead of vacuum ALD since at large scale it will reduce the investment costs and increase the throughput.<sup>20,21</sup> The ALD procedure of SiO<sub>2</sub> deposition is modified from the reported literature.<sup>22</sup> Nevertheless, the time settings of the reaction and the precursor gas flow rate we used were different. In brief, SiCl<sub>4</sub> and H<sub>2</sub>O serving as ALD reactants were kept in stainless-steel bubblers and evaporated at room temperature. N<sub>2</sub>, with a purity of 99.999%, was utilized as both the carrier and purging gas, and a gas flow of 0.5 L min<sup>-1</sup> was used throughout the whole process. The gas flowed parallel to the surface of the substrate in the reactor. The samples were pre-treated under air plasma at room temperature and at 4 mbar pressure for 60 seconds using a Harrick plasma machine before each experiment. The ALD reactor was heated and maintained at 100 °C for the entire ALD process. 15 seconds pulses were used to introduce SiCl<sub>4</sub> into the reactor, followed by 60 seconds purging with N<sub>2</sub> and 30 seconds dosing of H<sub>2</sub>O vapor. After that, 60 seconds purging with N<sub>2</sub> was used to finish a full ALD cycle. More detailed information on SiO<sub>2</sub> ALD operation conditions can be found in Table S1.† Samples with different numbers of ALD cycles were obtained by repeating the ALD cycles for the required times. At the end of synthesis process, the reactor



was purged with N<sub>2</sub> flow for 15 minutes and cooled down to room temperature.

### Material characterization

The JEOL JEM1400 transmission electron microscope (TEM) operating at 120 kV voltage was employed to examine and analyze the microstructures and particle size distribution of various catalysts. To assess the crystal structure of the catalysts, X-ray diffraction (XRD) measurements were conducted utilizing a Bruker D8 advance diffractometer with Bragg–Brentano geometry and a Lynxeye position-sensitive detector. The X-ray was generated using Cu K $\alpha$  radiation at 45 kV and 40 mA. The Pt concentration in the electrolyte was quantified using the inductively coupled plasma-optical emission spectrometry (ICP-OES) method, employing a PerkinElmer Optima 5300 DV ICP-OES instrument. X-ray photoelectron spectroscopy (XPS) measurements were performed employing a Thermo Scientific™ K-alpha™ (ThermoFisher™ Scientific) utilizing a monochromated X-ray of aluminum K $\alpha$  radiation (1486.7 eV) with a spot size of 400  $\mu$ m. For survey scans, a pass energy of 200 eV and a step size of 1 eV were used, while the high-resolution spectra were acquired with a pass energy of 50 eV and a step size of 0.1 eV. All peak positions were analyzed and calibrated, referencing the aliphatic C1s peak at 284.8 eV, using CasaXPS.

### Electrochemical measurements

The electrochemical measurements were conducted using a H-cell setup.<sup>23</sup> The preparation of the working electrodes involved a drop-casting technique. Initially, a catalyst ink was created by mixing 4 mg of catalyst with 800  $\mu$ L of deionized water, 150  $\mu$ L of isopropanol, and 50  $\mu$ L of Nafion perfluorinated resin solution. The mixture was sonicated in an ice bath for 1 hour. Subsequently, 50  $\mu$ L of the catalyst ink was drop cast onto the glassy carbon electrode surface, repeating the process 4 times. The prepared working electrodes were coated with SiO<sub>2</sub> using the ALD process, as described earlier, and subsequently used as working electrode. An Ag/AgCl electrode served as the reference electrode, while a graphite rod was utilized as the counter electrode. All potentials used in this work were converted to the RHE scale according to the equation:<sup>24</sup>

$$E_{\text{RHE}} = E_{\text{Ag/AgCl}} + 0.197 + 0.059 \times \text{pH}$$

0.5 M H<sub>2</sub>SO<sub>4</sub> was used as electrolyte in both chambers. A cation-exchange membrane, Nafion™ 117 (FuelCell store), was utilized to separate the anode and cathode chamber of the H-cell. A Biologic SP-200 potentiostat was employed to conduct the electrochemical measurements. Potentiostatic electrochemical impedance spectroscopy was used to measure the ohmic loss of the cell and was compensated for every experiment. An ADT was carried out by repeating CV scans for 1000 times between -0.2 V- 0.35 V vs. RHE at a scan rate of 50 mV s<sup>-1</sup>.<sup>23</sup> Linear sweep voltammetry (LSV)

was recorded from -0.3 V to 0 V vs. RHE at a scan rate of 2 mV s<sup>-1</sup>.

## Results and discussion

A series of SiO<sub>2</sub>-coated Pt/CB samples was prepared using ALD and compared with the uncoated Pt/CB sample. The deposition procedure used to prepare the coated samples can be found in the experimental section and Table S1.† In summary, the SiCl<sub>4</sub> vapor in a nitrogen stream and a humidified nitrogen stream was alternately fed into the home-built tubular flat substrate reactor<sup>25</sup> to initiate the layer by layer growth of SiO<sub>2</sub> on the surface of Pt/CB catalyst. By varying the number of coating cycles of the ALD process, the film thickness was changed accordingly. As can be seen in Fig. 1, the TEM images of the original Pt/CB catalyst indicate Pt nanoparticles of 3.2  $\pm$  0.5 nm (number-averaged diameter  $\pm$  standard deviation). Fig. 1 also shows that the average Pt particle size after SiO<sub>2</sub> ALD does not change considerably. The average Pt size measured through TEM imaging remains 3.2  $\pm$  0.5 nm and 3.2  $\pm$  0.6 for the sample with 5 and 20 ALD cycles, respectively. Considering the reported growth per cycle of SiO<sub>2</sub> using SiCl<sub>4</sub> in the employed experimental conditions, which is around 2 Å per cycle,<sup>26,27</sup> a very thin SiO<sub>2</sub> layer is expected even after 20 cycles of ALD coating. We have conducted the TEM characterization towards the outmost layer of the 20 cycles ALD coated sample, as shown in Fig. S1.† The film thickness of this sample is around 5.8 nm after 20 cycles ALD. This leads to an estimated growth per cycle for SiO<sub>2</sub> of 2.9 Å.

X-ray diffraction (XRD) analysis of the original Pt/CB catalyst and of the Pt/CB catalyst after applying a variant number of ALD cycles of SiO<sub>2</sub> coating were carried out to investigate the crystallinity of the catalysts. Fig. S2† shows that there is no significant distinction between the samples before and after SiO<sub>2</sub> ALD. Two strong carbon peaks are observed in the diffractogram, whereas the Pt signal is relatively weak and only a small peak at 39.8° that represents the Pt(111) plane is observed. SiO<sub>2</sub> peaks were not detected, as is expected since the SiO<sub>2</sub> grown by ALD is mostly amorphous.<sup>28</sup>

The uniform deposition of SiO<sub>2</sub> on the surface of the catalyst is confirmed with SEM-EDS (Fig. 2). The color bar on the left side of the SEM-EDS maps (Fig. 2a-c) is an indicator of the Si K $\alpha$  signal intensity in each sample. The SEM-EDS maps indicate that the surface concentration of Si increases with an increase in ALD cycles. It is worth noting that the EDS spectra also reveal a small peak of fluorine which originates from the Nafion™ polymer used as binder to stabilize the catalyst on the surface of the glassy carbon during the drop-casting process. XPS was employed to investigate the surface chemistry of the ALD coated Pt/CB samples. The Si 2p high-resolution spectra (Fig. S3†) suggest that Si in the studied samples exist in the SiO<sub>2</sub> state and can be deconvoluted into Si 2p<sub>3/2</sub> and Si 2p<sub>1/2</sub>. The Pt 4f peak intensity slightly diminishes as the number of ALD cycles





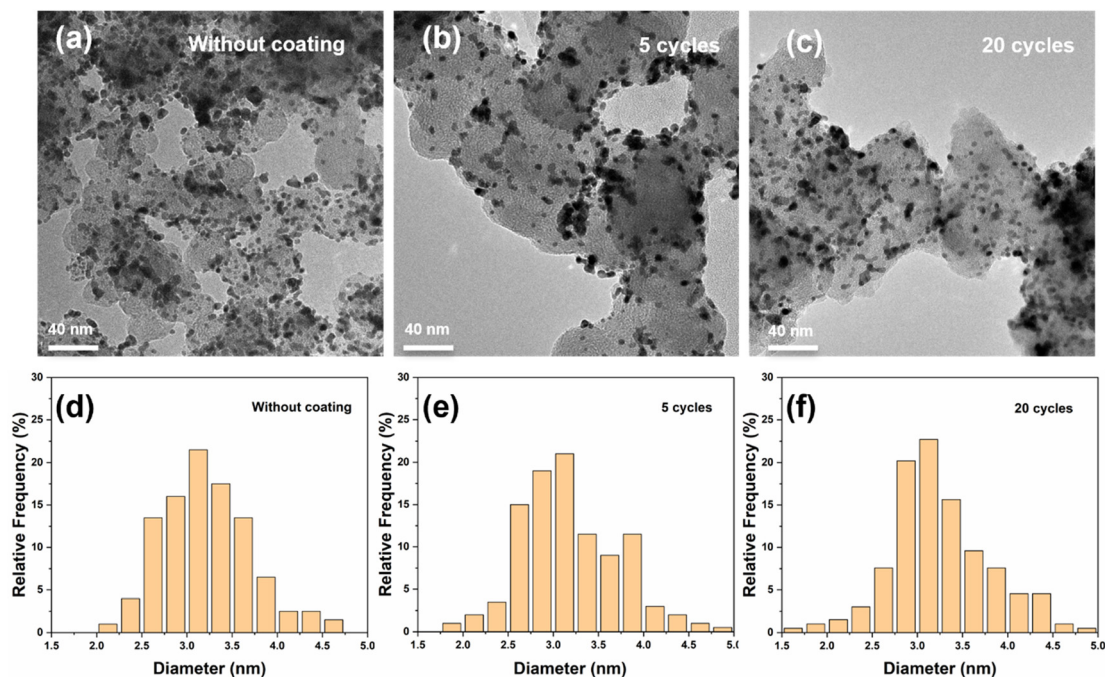


Fig. 1 TEM images and particle size distribution of Pt/CB catalysts before and after SiO<sub>2</sub> ALD coating: (a and d) original Pt/CB without ALD coating; (b and e) Pt/CB catalyst after 5 cycles of SiO<sub>2</sub> ALD coating, and (c and f) Pt/CB catalyst after 20 cycles of SiO<sub>2</sub> ALD coating.

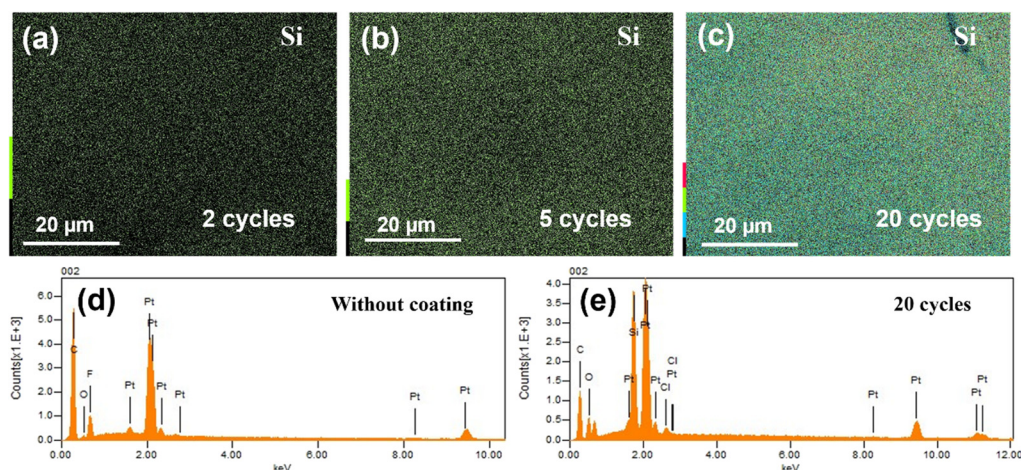


Fig. 2 SEM-EDS elemental mapping of the Pt/CB catalysts after SiO<sub>2</sub> ALD coating, the color bar indicates the Si K<sub>α</sub> signal intensity in each sample: (a–c) SEM images of Pt/CB catalysts after 2, 5, and 20 cycles of SiO<sub>2</sub> ALD coating; (d and e) EDS spectra of Pt/CB catalysts with and without 20 cycles of SiO<sub>2</sub> ALD coating.

increases from 2 to 5 cycles (Fig. 3a). However, it becomes vanishingly low after 20 cycles. This indicates a significant coating thickness of SiO<sub>2</sub> after 20 cycles of ALD, which is further supported by the peak intensity of Si shown in Fig. 3b. The Si peak intensity exhibits a slight increase as the number of ALD cycles increases, with a sharp rise after 20 ALD cycles. The analysis depth of XPS is about 4 nm,<sup>29,30</sup> and having a thicker SiO<sub>2</sub> film can strongly attenuate the signal underneath. The very weak Pt 4f peak in the sample coated with 20 ALD cycles compared to the bare sample suggests that the SiO<sub>2</sub> film is above 4 nm. In Fig. S4,<sup>†</sup> the SiO<sub>2</sub> growth

rate was characterized by XPS and EDS, respectively. Due to the detection depth variation of these two techniques,<sup>31</sup> Fig. S4<sup>†</sup> shows different Si atomic percentages on the surface of the identical sample. However, both characterizations methods show a monotonic increase of the Si atomic percentage as a function of ALD cycles applied.

XPS line scanning was conducted to investigate the SiO<sub>2</sub> uniformity on the catalyst surface. Photoelectron signals were collected from the scanning line through the whole catalyst region, extended to the bare surface of the glassy carbon substrate, and plotted as the function of the horizontal distance.



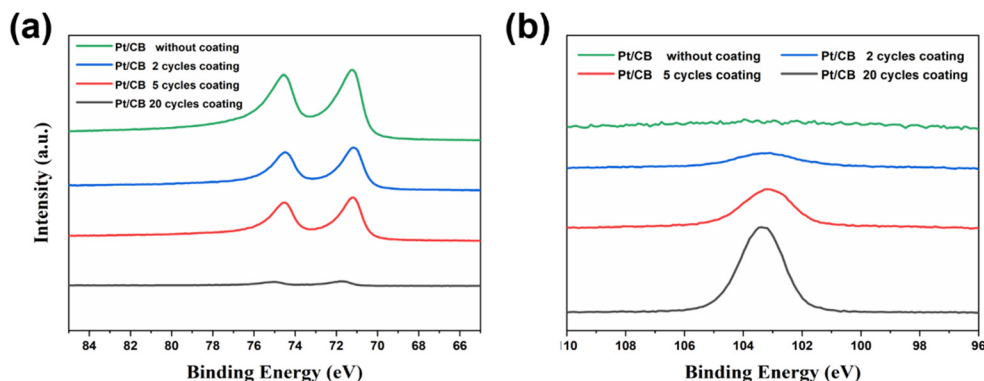


Fig. 3 The Pt and Si XPS spectra of the Pt/CB catalyst with and without SiO<sub>2</sub> coating: (a) Pt 4f XPS spectra, (b) Si 2p XPS spectra.

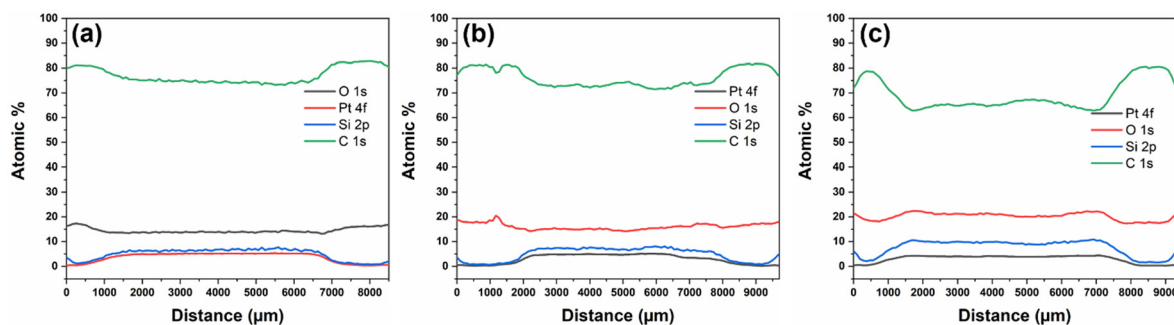


Fig. 4 XPS line scan profiles of Pt/CB catalyst after SiO<sub>2</sub> ALD coating: (a) 2 ALD cycles, (b) 5 ALD cycles, and (c) 20 ALD cycles of SiO<sub>2</sub> coating.

As can be seen from Fig. 4, the surface concentration of Pt 4f, Si 2p, and O 1s reveals a step increase and decrease, indicating the region where the catalyst is drop casted.

The Si 2p and O 1s signals follow the trend of the Pt 4f signal along the line. The C 1s signal shows a trough in the catalyst spot region, stemming from the emerging SiO<sub>2</sub> coverage and the higher Pt atomic percentage in the catalyst region. The Si concentration on the surface of the drop casted catalyst area is significantly higher than on the bare glassy carbon substrate at the edges and increases with the number of ALD cycles. A similar trend can also be seen for the O 1s signal. This observation suggests that the SiO<sub>2</sub> growth rate is much higher on the catalyst surface than on the glassy carbon substrate, and results in selective deposition of SiO<sub>2</sub> on the surface of the Pt/CB catalyst. Two crossover XPS line scans in every sample show comparable results in the X and Y axis, indicating the homogeneity of the catalyst region on the glassy carbon substrate (see Fig. S5†).

To further investigate the SiO<sub>2</sub> distribution on the catalyst area and the glassy carbon substrate, XPS area scans were conducted (Fig. S6 and S7†). The area scan reveals that Pt is homogeneously dispersed over the catalyst region and there is no Si signal detected on the surface of the original Pt/CB catalyst (Fig. S6†). After 5 SiO<sub>2</sub> ALD cycles, the Si 2p signal is clearly visible in Fig. S7† and aligns with Pt/CB region. This again indicates selective deposition of SiO<sub>2</sub> on the catalyst surface rather than on the glassy carbon substrate.

The effect of different thicknesses of SiO<sub>2</sub> coating on the Pt stability during electrochemical hydrogen evolution was evaluated in a H-cell using a 0.5 M H<sub>2</sub>SO<sub>4</sub> electrolyte. ADT of the catalysts were conducted similar to literature procedures.<sup>32,33</sup> In brief, cyclic voltammograms were recorded with a scan rate of 50 mV s<sup>-1</sup> from 0.35 V to -0.20 V vs. RHE for 1000 cycles. Linear sweep voltammograms (LSV) were recorded before and after the ADT to measure the catalytic activity of the electrode toward hydrogen evolution (Fig. 5). For the Pt/CB catalyst without ALD coating, the current density at -0.20 V vs. RHE was reduced by 34% in the water reduction potential range after the ADT. By contrast, the catalyst coated with 2 ALD cycles of SiO<sub>2</sub> showed a current density reduction at the same voltage of only 7% after the same ADT procedure. After applying 5 cycles of SiO<sub>2</sub> ALD, the catalyst current density was merely reduced by 2% after the ADT. The Nyquist plots shown in Fig. S8† indicate that the charge transfer resistance between the catalysts with and without 5 cycles of ALD coating is comparable. This means that the SiO<sub>2</sub> coating didn't hinder the proton transfer to the Pt catalyst within 5 cycles of ALD coating. However, 20 cycles of SiO<sub>2</sub> deposition showed an inhibitory effect on the catalytic activity, with a 65% decrease in the HER activity compared to the uncoated sample. This indicates that 20 cycles of ALD results in a too thick SiO<sub>2</sub> layer, possibly hindering the electron transfer and suppressing the HER. However, the HER activity of the sample coated with 20 ALD cycles of SiO<sub>2</sub> increased 94% post ADT. Zhuravlev<sup>34</sup>



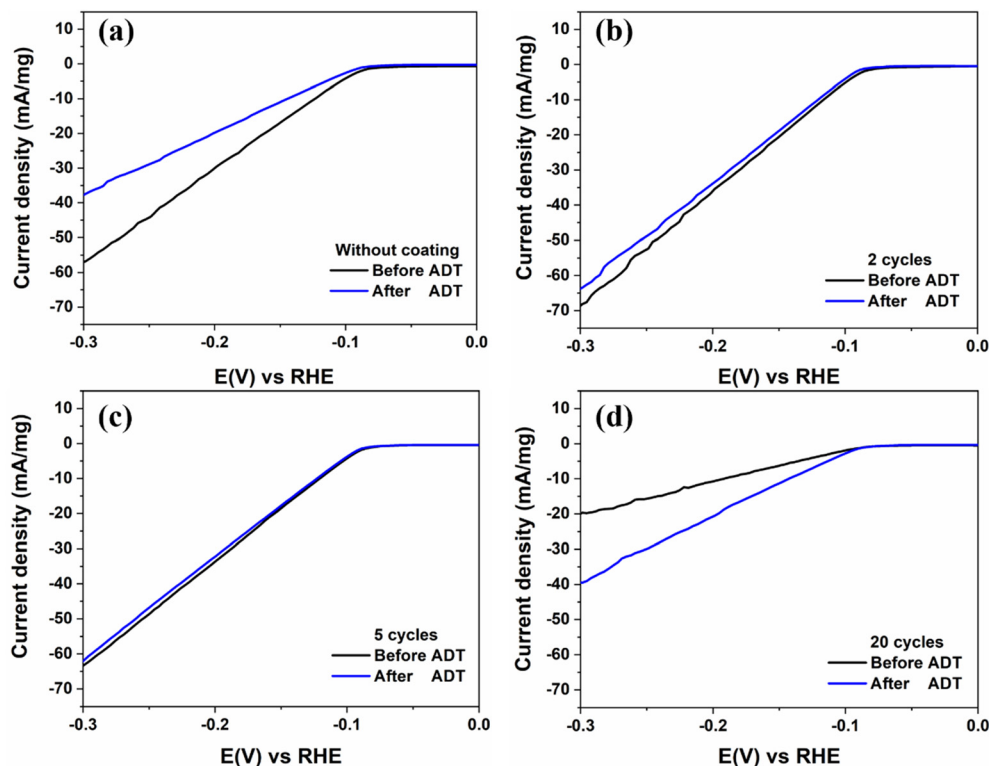


Fig. 5 Linear sweep voltammogram (LSV) curves of the Pt/CB catalysts before and after accelerated durability tests: (a) original catalyst, Pt/CB catalyst coated with SiO<sub>2</sub> using (b) 2 ALD cycles, (c) 5 ALD cycles, and (d) 20 ALD cycles.

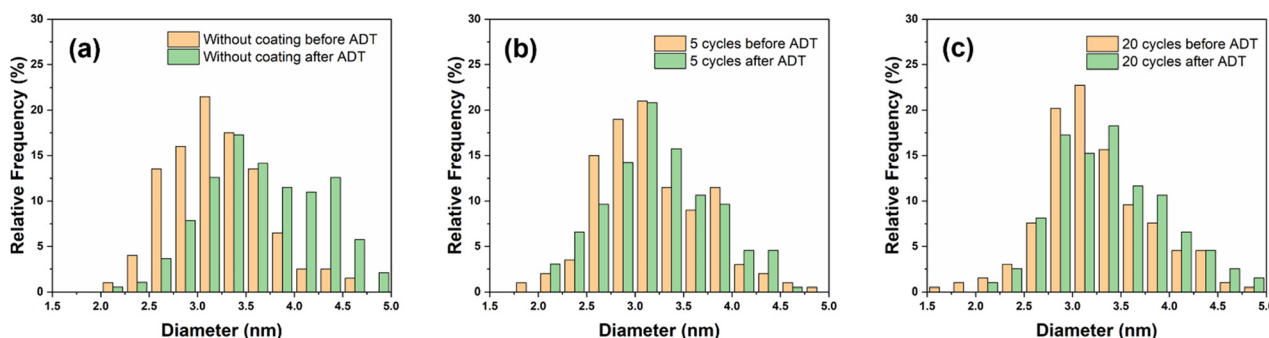


Fig. 6 Particle size distribution of the Pt/CB catalyst before and after ADT: (a) original catalyst, Pt/CB catalyst coated with SiO<sub>2</sub> using (b) 5 ALD cycles, (c) 20 ALD cycles.

summarized that the surface hydroxyl groups in SiO<sub>2</sub> can form due to the rehydroxylation of SiO<sub>2</sub> in aqueous solutions, and the surface SiO<sub>2</sub> atoms' free valence tend to become saturated with hydroxyl groups in aqueous medium. This process can also happen on our SiO<sub>2</sub> layer, especially during the ADT process. Kang *et al.*<sup>35</sup> reported that the silicon hydroxide deposited on the surface of anion-exchange membrane can drastically increase the proton transport number in the membrane. We hypothesize that the increase of silanol groups on the surface of SiO<sub>2</sub> during ADT helps to improve proton transfer in relatively thick SiO<sub>2</sub> layers. Consequently, this process partially restores the HER activity and increases the current density of the 20 cycles coated sample after the ADT procedure.

The particle size distribution (PSD) analysis (shown in Fig. 6) of Pt/CB catalysts before and after the ADT tests demonstrates that the average particle size of the Pt/CB catalyst without ALD coating increased from  $3.2 \pm 0.5$  nm to  $3.7 \pm 0.7$  nm after the ADT, an increase of 16%. In comparison, the particle size of the Pt particles only increased from  $3.2 \pm 0.5$  nm to  $3.3 \pm 0.6$  nm after being protected by 5 cycles of SiO<sub>2</sub> ALD coating, an increase of 3% after the ADT. This proves that the SiO<sub>2</sub> coating prevents catalyst growth/agglomeration during the ADT, which is one of the main deactivation mechanisms of Pt electrocatalysts during water electrolysis. Fig. S9† further displays the Pt particle size evolution from TEM imaging after the ADT. Also, Fig. S10 and S11† show that without SiO<sub>2</sub> ALD coating, the





**Table 1** Pt concentration in the electrolyte after ADT, tested by ICP-OES

Sample	Pt concentration (mg L <sup>-1</sup> )
Fresh 0.5 M H <sub>2</sub> SO <sub>4</sub> electrolyte	<0,02
Pt/CB without ALD coating	8.94
Pt/CB with 2 cycles coating	4.11
Pt/CB with 5 cycles coating	1.94
Pt/CB with 20 cycles coating	1.48

bare Pt/CB catalyst surface becomes rougher, and cavities can be seen on the catalyst surface. However, with SiO<sub>2</sub> ALD, the surface of the catalyst before and after the ADT remains nearly similar. The electrolyte after the ADT was collected and analyzed by ICP-OES to measure the Pt concentration in the electrolyte before and after the ADT, and the resulting data is summarized in Table 1. Before the ADT, the Pt concentration in the electrolyte is near 0 mg L<sup>-1</sup>. During the ADT, the Pt/CB catalyst gradually degrades, and we observed an increase in Pt concentration to 8.9 mg L<sup>-1</sup> in the Pt/CB sample without ALD coating after ADT. However, after applying 2 cycles of SiO<sub>2</sub> ALD, the Pt concentration in the electrolyte reduced to 4.1 mg L<sup>-1</sup> post ADT. Applying 5 cycles of SiO<sub>2</sub> coating further decreased the Pt concentration in the electrolyte to 1.9 mg L<sup>-1</sup>. Nevertheless, continuing to increase the ALD coating to 20 cycles only caused a minor decrease in Pt concentration and did not significantly enhance the protection effect. This might be due to the crack formation on the relatively thick coating during the ADT process decreasing its protection ability.<sup>36</sup> This process can take place since the flexibility of SiO<sub>2</sub> decreases as the thickness increases and it has very low coefficient of expansion.<sup>37</sup> This implies that simply increasing ALD cycles to further reduce the Pt detachment after ADT is very challenging. The electrochemical oxidation potential of Pt is above 1.2 V vs. RHE.<sup>38</sup> Hence, Pt leaching during the ADT process should be negligible. The main mechanism for the Pt concentration increase after the ADT process should therefore be Pt detachment from the Pt/CB catalyst or catalyst peel off from the electrode. Overall, we show that the ultrathin SiO<sub>2</sub> layers deposited *via* ALD can be used to strongly reduce the Pt catalyst agglomeration and detachment during water splitting reaction.

## Conclusions

ALD was employed to coat the surface of Pt/CB electrocatalysts with an ultrathin layer of SiO<sub>2</sub> to prevent deactivation during water electrolysis. Our findings show that without SiO<sub>2</sub> coating, the current density of the untreated Pt/CB catalyst was reduced by 34% at -0.2 V vs. RHE after an ADT. However, after coating the Pt/CB catalyst with 2 SiO<sub>2</sub> ALD cycles, the current density was only reduced by 7% under the same conditions. With 5 SiO<sub>2</sub> ALD cycles, the current density decrease was 2%. The Pt particle size increased by 16% after ADT without SiO<sub>2</sub> coating, but only by 3% after being protected by 5 cycles of SiO<sub>2</sub> deposition.

Additionally, we observed severe Pt detachment after the ADT in the Pt/CB catalyst without ALD coating, with the Pt concentration in the electrolyte increasing to 8.9 mg L<sup>-1</sup> after ADT. The Pt detachment can be alleviated by the ultrathin SiO<sub>2</sub> coating synthesized by ALD. After applying 5 cycles of SiO<sub>2</sub> ALD, the Pt detachment/dissolution was reduced to one-fifth compared to the sample without ALD coating. In summary, a nanoscale SiO<sub>2</sub> protective layer strongly reduces Pt agglomeration and detachment during the hydrogen evolution reaction in acidic conditions. By performing just a few ALD cycles, keeping this coating ultrathin, an inhibitory effect on the electrocatalytic activity is avoided.

## Author contributions

M. Li: conceptualization, methodology, formal analysis, validation, writing – original draft. S. Saedy: conceptualization, formal analysis, visualization, writing – review & editing. S. Fu: methodology, resources, investigation, writing – review & editing. T. Stellema: data curation, methodology, formal analysis, validation, visualization. R. Kortlever: supervision, writing – review & editing, project administration. J. R. van Ommen: supervision, writing – review & editing, funding acquisition.

## Conflicts of interest

There are no conflicts to declare.

## Acknowledgements

M. L. and S. F. acknowledge the PhD scholarship awarded by the China Scholarship Council (CSC). The authors thank Mojgan Talebi for the help in the lab, Bart Boshuizen for the XPS line scan and XPS area scan training, Ruud Hendrikx for the XRD testing and Baukje Terpstra for the ICP-OES analysis.

## References

- H. Jin, B. Ruqia, Y. Park, H. J. Kim, H. S. Oh, S. I. Choi and K. Lee, *Adv. Energy Mater.*, 2020, **11**, 2003188.
- D. Merki and X. Hu, *Energy Environ. Sci.*, 2011, **4**, 3878–3888.
- X. K. Wan, H. B. Wu, B. Y. Guan, D. Luan and X. W. D. Lou, *Adv. Mater.*, 2020, **32**, e1901349.
- N. Cheng, S. Stambula, D. Wang, M. N. Banis, J. Liu, A. Riese, B. Xiao, R. Li, T. K. Sham, L. M. Liu, G. A. Botton and X. Sun, *Nat. Commun.*, 2016, **7**, 13638.
- S. Cherevko, N. Kulyk and K. J. J. Mayrhofer, *Nano Energy*, 2016, **29**, 275–298.
- C. Marichy, G. Ercolano, G. Caputo, M. G. Willinger, D. Jones, J. Rozière, N. Pinna and S. Cavaliere, *J. Mater. Chem. A*, 2016, **4**, 969–975.
- H. J. Kim, D. H. K. Jackson, J. Lee, Y. Guan, T. F. Kuech and G. W. Huber, *ACS Catal.*, 2015, **5**, 3463–3469.
- Y. Shao, J. Liu, Y. Wang and Y. Lin, *J. Mater. Chem.*, 2009, **19**, 46–59.





- 9 Z. Liu, V. Bode, P. Hadayati, H. Onay and E. J. R. Sudhölter, *Fuel*, 2020, **280**, 118650.
- 10 S. Ghanbari, E. Kazemzadeh, M. Soleymani and A. Naderifar, *Colloid Polym. Sci.*, 2015, **294**, 381–388.
- 11 Z. W. Liwei Wang, H. Yang and G. Yang, *Materials Science Communication*, 1998, **57**, 260–263.
- 12 M. Liehr, J. E. Lewis and G. W. Rubloff, *J. Vac. Sci. Technol., A*, 1987, **5**, 1559–1562.
- 13 S. Wang, K. Feng, D. Zhang, D. Yang, M. Xiao, C. Zhang, L. He, B. Yan, G. A. Ozin and W. Sun, *Adv. Sci.*, 2022, **9**, e2104972.
- 14 L. Li, H. Chen, C. Zhang and Z. Fei, *Mol. Catal.*, 2019, **469**, 155–160.
- 15 C. Trompoukis, J.-Y. Feng, T. Bosserez, J. Rongé, J. Dendooven, C. Detavernier, R. Baets and J. A. Martens, *Sustainable Energy Fuels*, 2021, **5**, 3115–3123.
- 16 S. Takenaka, H. Matsumori, H. Matsune and M. Kishida, *Appl. Catal., A*, 2011, **409–410**, 248–256.
- 17 W. C.-Y. Ma, H.-S. Hsu, C.-C. Fang, C.-Y. Jao and T.-H. Liao, *Thin Solid Films*, 2018, **660**, 926–930.
- 18 K. Kato, T. Mori, Y. Morita, T. Matsukawa, M. Takenaka and S. Takagi, *Appl. Phys. Express*, 2020, **13**, 074004.
- 19 H. Van Bui, F. Grillo and J. R. van Ommen, *Chem. Commun.*, 2016, **53**, 45–71.
- 20 K. S. Yoo, D.-G. Kim, S. Lee, W.-B. Lee and J.-S. Park, *Ceram. Int.*, 2022, **48**, 18803–18810.
- 21 D. H. Levy, D. Freeman, S. F. Nelson, P. J. Cowdery-Corvan and L. M. Irving, *Appl. Phys. Lett.*, 2008, **92**, 192101.
- 22 D. La Zara, F. Sun, F. Zhang, F. Franek, K. Balogh Sivars, J. Horndahl, S. Bates, M. Brannstrom, P. Ewing, M. J. Quayle, G. Petersson, S. Folestad and J. R. van Ommen, *ACS Nano*, 2021, **15**, 6684–6698.
- 23 P. N. Pintauro and J. R. Bontha, *J. Appl. Electrochem.*, 1991, **21**, 799–804.
- 24 L. Wang, C.-Y. Lee and P. Schmuki, *J. Mater. Chem. A*, 2013, **1**, 212–215.
- 25 A. Santoso, A. Damen, J. R. van Ommen and V. van Steijn, *Chem. Commun.*, 2022, **58**, 10805–10808.
- 26 Y. Du, X. Du and S. M. George, *Thin Solid Films*, 2005, **491**, 43–53.
- 27 J. W. Klaus, O. Sneh and S. M. George, *Science*, 1997, **278**, 1934–1936.
- 28 J. Guo, D. Benz, T.-T. Doan Nguyen, P.-H. Nguyen, T.-L. Thi Le, H.-H. Nguyen, D. La Zara, B. Liang, H. T. Hintzen, J. R. van Ommen and H. Van Bui, *Appl. Surf. Sci.*, 2020, **530**, 147244.
- 29 T. A. Carlson and G. E. McGuire, *J. Electron Spectrosc. Relat. Phenom.*, 1972, **73**, 161–168.
- 30 B. R. Strohmeier, *Surf. Interface Anal.*, 1990, **15**, 51–56.
- 31 K. Rokosz, T. Hryniewicz, D. Matysek, S. Raaen, J. Valicek, L. Dudek and M. Harnicarova, *Materials*, 2016, **9**, 318.
- 32 M. Smiljanić, M. Bele, F. Ruiz-Zepeda, M. Šala, A. Kroflič and N. Hodnik, *Electrochim. Acta*, 2021, **400**, 139435.
- 33 Y. Lai, Z. Zhang, Z. Zhang, Y. Tan, L. Yu, W. Wu, Z. Wang, T. Jiang, S. Gao and N. Cheng, *Chem. Eng. J.*, 2022, **435**, 135102.
- 34 L. T. Zhuravlev, *Colloids Surf., A*, 1999, **173(2000)**, 1–38.
- 35 M. S. Kang, Y. J. Choi, H. J. Lee and S. H. Moon, *J. Colloid Interface Sci.*, 2004, **273**, 523–532.
- 36 M. Putkonen, M. Bosund, O. M. E. Ylivaara, R. L. Puurunen, L. Kilpi, H. Ronkainen, S. Sintonen, S. Ali, H. Lipsanen, X. Liu, E. Haimi, S.-P. Hannula, T. Sajavaara, I. Buchanan, E. Karwacki and M. Vähä-Nissi, *Thin Solid Films*, 2014, **558**, 93–98.
- 37 H. Shan, X. Wang, F. Shi, J. Yan, J. Yu and B. Ding, *ACS Appl. Mater. Interfaces*, 2017, **9**, 18966–18976.
- 38 S. Bawari, T. N. Narayanan and J. Mondal, *Electrochem. Commun.*, 2023, **147**, 107440.

